

Confirmation no. 3423

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:	DE BOER	Examiner:	Lund, J.
Serial No.:	10/537,363	Group Art Unit:	1792
Filed:	June 2, 2005	Docket No.:	US020527US
Title:	SYSTEM AND METHOD FOR SUPPRESSION OF WAFER TEMPERATURE DRIFT IN COLD-WALL CVD SYSTEMS		

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AMENDMENT AND RESPONSE

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Customer No. <b>65913</b>
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Dear Sir:

In response to the non-final Office Action dated December 17, 2007, please consider the following amendments and remarks.

A complete listing of the Claims, to include any amendments thereto, begins on page 2 of this paper.

Remarks/Arguments follow on page 5.

Authorization is given to charge/credit Deposit Account 50-0996 (NXPS.441PA) all required fees/overages to enter this paper.